



IFW

PATENT  
Docket No. 606402001810

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the application of:

Nobuyuki SEKIKAWA *et al.*

Serial No.: 10/720,378

Filing Date: November 25, 2003

For: METHOD OF MANUFACTURING  
INSULATED GATE  
SEMICONDUCTOR DEVICE

Examiner: Shrinivas H. Rao

Group Art Unit: 2814

Conf. No.: 4282

**AMENDMENT UNDER 37 CFR 1.111**

MS Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Action mailed March 8, 2006, please amend this application as follows:

**The amendments to the specification begin on page 2.**

**The listing of claims begins on page 3.**

**The Remarks begin on page 6.**